

Photomask / Lithography Ad Special

We hereby announce "The plan of Photomask/Lithography Ad Special" on SIJ Mar issue. Photomask Japan 2009 is the 16th annual international symposium on photomasks and NGL masks in Japan. This symposium will be held on 8/Apr-10/Apr 2009 at the Pacifico Yokohama. The aim of the symposium is to bring together engineers and investigators from Japan, USA, and all over the world in the field of photomasks, NGL masks, and related technologies to discuss recent progress, applications, and future trends.

This Advertisement Focus Special will be consists of following contents and Bonus contents, please see the information below ;

We believe this special will give big influence to increasing your products visible in advanced Semiconductor manufacturing.

Contents

Contents

- Technology view of Photomask/Lithography
- Information and overview of Photomask Japan 2009

Issue

Mar. Issue : Mar/19/2009(Publication date)

Bonus contents

SIJ Mar issue will be handed out to all attendees with proceeding at Photomask Japan 2009 registration desk
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Ad Date

Ad closing 17/Feb/2009
Material due 23/Feb/2009

非接触式シート抵抗測定システム 「Model NC-1000」

NC-1000は有機EL、カラーフィルターなどのITO膜、各種メタル膜を渦電流法による非接触でシート抵抗を高精度に測定します。測定は3列のセンサーにより、等間隔で多点測定可能。標準システムはセミオート仕様。オプションによるフルオート仕様への拡張や、マップの表示なども可能。測定範囲は各膜種により選択可能。



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Data

Text :

Products and Services
Title text:20Japanese words
Body text: 140-180Japanese words

Photo or Chart

1 item (300bpi)

Contacts :

Company/TEL/FAX
Email/URL

Material Due:

20/Feb/2009

Send data :

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Please send email to Ogata

Sample Products Show Case 1/6 page

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